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Mechanism of Ethylene Oxychlorination on Ceria

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Supporting Information

ABSTRACT: Ethylene oxychlorination on CeO_2 provides ethylene dichloride (EDC) and the desired vinyl chloride (VCM) in a single operation, in contrast to the traditional process that requires two separate units. The origin of this outstanding performance is unclear, and the mechanism has not been discussed in detail. In the present work, we combine density functional theory (DFT) with steady-state experiments and temporal analysis of products (TAP) to close this gap. The catalyst surface is found to contain CeOCl, while the bulk phase is CeO₂, regardless of the starting materials CeCl₃, CeOCl, or CeO₂. Catalysis by different nanostructures highlights that the CeO₂(111) surface is more active than the (100) surface due to the poisoning of the latter, while the selectivities are comparable. In any case, the degree of oxygen removal from CeO₂ and the



replenishment of the accordingly formed oxygen vacancies by Cl and its replenishment by Cl species lead to increased selectivity to chlorinated products and decreased selectivity to carbon oxides. DFT and TAP studies reveal that the most likely pathway of VCM formation takes place by a cascade reaction. First, EDC appears and then HCl is extracted in a concerted step to lead to VCM. Such steps are a key characteristic of ceria. Other paths leading to minor products such as 1,2-dichloroethene (DCE) are found possible by starting from VCM or EDC. CO is formed by combustion of chlorinated species, whereas CO_2 can either stem from further oxidation of CO or directly from ethylene. In summary, our work points out a rich complex behavior of the chemistry of chlorinated compounds on the oxide surface, indicating that concerted steps and cascade reactions are possible for these materials.

KEYWORDS: ethylene oxychlorination, mechanism, CeO₂, oxychloride, oxygen vacancies, density functional theory, temporal analysis of products

1. INTRODUCTION

Polyvinyl chloride (PVC) constituted a 53 billion USD market in 2015, growing with a compound annual growth rate of 5.3%.¹ Its corresponding monomer, vinyl chloride (commonly denoted as VCM), is produced through hydrochlorination of acetylene²⁻⁴ or through energy-intensive thermal dehydrochlorination of 1,2-dichloroethane (known as ethylene dichloride, EDC) with a low yield of 49–58%.⁵ EDC is, in turn, formed either by Cl₂ addition to ethylene or by ethylene oxychlorination. The latter enables recycling of HCl from the dehydrochlorination step in the balanced VCM process.^{5–7} To date, the catalyst in ethylene oxychlorination comprises cupric chloride (CuCl₂) as the active phase, impregnated on a porous support such as alumina, and is promoted by numerous alkali, alkaline-earth, and rare-earth metals to reduce the copper loss and/or improve the activity and selectivity.^{8–11} However, while an EDC selectivity of 99% is achieved, issues surrounding active phase volatilization or particle stickiness have not yet been fully resolved.¹² Nevertheless, the mechanism of ethylene oxychlorination on CuCl₂-based catalysts has been unveiled by numerous in situ and operando spectroscopy studies.^{13–17} Briefly, the process encompasses a three-step redox mechanism: (i) chlorination of ethylene by reduction of CuCl₂ to CuCl, (ii) formation of a cupric oxychloride by oxidation of CuCl, and finally (iii) closure of the catalytic cycle though rechlorination of the oxychloride with HCl and water elimination. $^{6,9,10,13,14,16,18-26}$

Recently, the great potential of CeO₂ in ethylene oxychlorination was uncovered, revealing a stable bifunctional character and enabling direct VCM and EDC production with single-step yields up to 25%.²⁷ Some of us put forward that this VCM formation can be attributed to the material acidity, correlating with the EDC dehydrochlorination performance of CeO₂, and that higher chlorination leads to higher EDC selectivity and suppressed oxidation routes.²⁷ Alternative materials, also based on rare-earth elements, such as EuOCl, were less active but highly selective toward VCM (75%) and evidenced the selectivity-acidity link.28 However, a previous study aiming to shed light on the complex ethylene oxychlorination reaction network on oxide- or oxychloridebased materials used density functional theory (DFT) on RuO2 as a model catalyst due to the simple electronic structure. RuO₂ is a poor oxychlorination catalyst, as it mostly forms CO₂ and only small amounts of EDC and VCM during the reaction. Nevertheless, investigation of 34 elementary steps over the relatively simple surface revealed that oxidation processes are thermodynamically favored, whereas chlorination processes are kinetically controlled.²⁹ In addition, the surface chlorine uptake, i.e., the chlorine coverage, is a key factor determining the selectivity of RuO₂. Only high chlorine coverage allows VCM displacement by C₂H₄, thus preventing the formation of VCMderived products; however at the same time it destabilizes C₂H₄Cl intermediates, favoring the formation of EDC instead of VCM.2

In this study, we investigate the mechanism of ethylene oxychlorination over CeO2, as it was the most active under a broad range of conditions and exhibited a strong effect of the feed concentrations of HCl and O2 on the activity and selectivity to chlorinated products.^{27,28} In addition, CeO₂ shows a correlation between dehydrochlorination performance and surface acidity, the exact nature of which is as yet unknown. Even though CeO₂ has a more complex electronic structure than RuO₂, the computational setup based on DFT+U has proven reasonably accurate.³⁰⁻³⁶ As our experiments reveal that the active phase in oxychlorination is actually an oxychloride, previous studies of the mechanism of oxychlorination on RuO₂ and chlorination of RuO2 and CeO2 in the related HCl oxidation potentially allow knowledge transfer to this work or accompany our findings.^{29,32,37-40} We prove and complement the theoretical insight by DFT with advanced transient kinetic studies, uncovering the reaction pathways that lead to chlorinecontaining hydrocarbons and suggesting the routes for combustion.

2. MATERIALS AND METHODS

2.1. Catalyst Preparation. Commercial CeO₂ (Sigma-Aldrich, 99.5%) was calcined at 873 or 1023 K in static air using a heating rate of 5 K min⁻¹ and an isothermal step of 5 h prior to its use in the catalytic studies. CeCl₃ (ABCR, 99.9%) was calcined at 423 K in static air using a heating rate of 5 K min⁻¹ and an isothermal step of 5 h in order to desorb any adsorbed species, while not transforming it to CeO₂. The catalysts are hereafter denoted as CeCl₃/CeO₂-x(-py)(-Ez), where x is the calcination temperature in K, y the prereduction temperature in K if applied, and Ez indicates the material used in ethylene oxychlorination at a reaction temperature of z in K. CeOCl was prepared by calcination at 1023 K, following the method reported by Farra et al.⁴¹ CeO₂ nanocubes (CeO₂-NC) were

hydrothermally synthesized, with optimization of procedures reported elsewhere.^{42–44} Briefly, 5.21 g of $Ce(NO_3)_3$ · $6H_2O$ was dissolved in 30 mL of distilled water to which 210 mL of 6.9 M NaOH solution was added dropwise under vigorous stirring. After precipitation, the suspension was transferred into a Teflon-lined cylinder, sealed in a stainless-steel autoclave, and kept at 453 K for 24 h. Subsequently, the suspension was cooled to room temperature, centrifuged, and washed three times with water and ethanol before the product was dried overnight at 333 K and calcined in static air at 773 K for 3 h.

2.2. Catalyst Characterization. N2 sorption at 77 K was measured in a Quantachrome Quadrasorb-SI analyzer. Prior to the measurements, the samples were outgassed to 50 mbar at 573 K for 12 h. The Brunauer–Emmett–Teller (BET) method was applied to calculate the total surface area, S_{BET} , in m² g⁻¹.⁴⁵ Oxygen storage capacity (OSC) measurements were performed by thermogravimetric analysis (TGA) on a TA Instruments Q500 apparatus. The sample (30 mg) was loaded on a platinum pan and pretreated in N_2 (60 cm³ STP min⁻¹) at 573 K for 1 h, then the temperature was ramped up to 673 K and equilibrated for 15 min. Thereafter, a flow with 4.5 vol % H₂ in N_2 (60 cm³ STP min⁻¹) was introduced and maintained for 2 h (first OSC measurement) before purging with N_2 for 5 min and reoxidizing the sample with air $(60 \text{ cm}^3 \text{ STP min}^{-1})$ for 1 h. After a second purge in N2 for 5 min, a second OSC measurement was performed under identical conditions. Then, two more OSC measurements were performed, following the same procedure in order to ensure that no chlorine removal would impair the measured OSC. The chlorine content in the used samples was estimated by four independent X-ray fluorescence (XRF) spectroscopy measurements using an Orbis PC Micro-EDXRF analyzer with a Rh source (35 kV, 500 μ A) and a silicon drift detector. A chlorine background signal was determined in four fresh CeO₂-873 at 0.3 atom % and subtracted from all averaged measurements. Powder X-ray diffraction (XRD) was measured using a PANalytical X'Pert PRO-MPD diffractometer and Cu K α radiation (λ = 0.15418 nm). The data were recorded in the $10-70^{\circ} 2\theta$ range with an angular step size of 0.017° and a continuing time of 0.26 s per step.

2.3. Catalytic Testing. The steady-state oxychlorination of ethylene was investigated at ambient pressure in a continuousflow fixed-bed reactor (Scheme S1). The setup consists of (i) mass flow controllers to feed C₂H₄ (PanGas, 3.5), HCl (Air Liquide, 2.8, anhydrous), O2 (Messer, 19.96% in He), He (PanGas, 5.0) as a carrier gas, and Ar (PanGas, 5.0) as an internal standard, (ii) a syringe pump (Nexus 6000, Chemyx) to feed EDC (Fluka, 99.5%), (iii) a vaporizer operated at 403 K accommodating a quartz T-connector filled with glass beads to vaporize EDC, (iv) an electrically heated oven hosting a quartz microreactor equipped with a K-type thermocouple whose tip reaches the center of the catalyst bed, (v) downstream heat tracing to avoid any condensation of the reactants and products, and (vi) a gas chromatograph coupled to a mass spectrometer (GC-MS) for online analysis. The effluent stream was neutralized by passing it through an impinging bottle containing an aqueous NaOH solution (1 M). The catalyst $(W_{\text{cat}} = 0.5 \text{ g, particle size } d_{\text{p}} = 0.4 - 0.6 \text{ mm})$ was loaded in the microreactor (10 mm inner diameter) and pretreated in He at 473 K for 30 min. Thereafter, a total flow $(F_{\rm T})$ of 100 cm³ STP min⁻¹ with a composition of C_2H_4 :HCl:O₂:Ar:He = 3:(1-6): (1-6):3:(83.2-90), where Ar acted as internal standard and He was used as carrier gas, was fed to the reactor at a bed

temperature (T) of 423–773 K and pressure (P) of 1 bar. Note that relatively low feed concentrations were selected to prevent corrosion, enable safe handling, and minimize the formation of hot spots in the catalyst bed due to the high reaction exothermicity. The standard C_2H_4 :HCl:O₂:He = 3:4.8:3:89.2 feed was chosen on the basis of the literature.^{12,27} Prior to the analysis of the reaction mixtures, the catalysts were equilibrated for at least 1 h under each condition. The gas composition at the reactor outlet, containing reactants (C₂H₄, O₂, HCl) and products (EDC, VCM, DCE, EC, CO, CO₂), was determined online using a gas chromatograph equipped with a GS-CarbonPLOT column coupled to a mass spectrometer (Agilent GC 7890B, Agilent MSD 5977A) with a triple-axis detector and an electron multiplier. A representative chromatogram is depicted as an inset in Scheme S1. In the HCl oxidation tests, the Cl₂ production was quantified by offline iodometric titration (using a Mettler Toledo G20 Compact Titrator) of triiodide, formed by purging the Cl2-containing reactor outlet through an aqueous KI (Sigma-Aldrich, 99.5%) solution (0.1 M), with 0.01 M sodium thiosulfate solution (Sigma-Aldrich, 99.99%). The conversion of HCl in HCl oxidation experiments, X(HCl), was calculated using eq 1

$$X(\text{HCl}) = \frac{2x_{\text{Cl}_2,\text{outlet}}}{x_{\text{HCl,inlet}}} \times 100\%$$
(1)

where $x_{\text{HCl,inlet}}$ and $x_{\text{Cl}_2\text{outlet}}$ denote the volumetric concentration of HCl and Cl₂ at the reactor inlet and outlet, respectively. The conversion of ethylene in ethylene oxychlorination experiments, $X(C_2H_4)$, was calculated according to eq 2

$$X(C_{2}H_{4}) = \frac{x_{C_{2}H_{4},\text{inlet}} - x_{C_{2}H_{4},\text{outlet}}}{x_{C_{2}H_{4},\text{inlet}}} \times 100\%$$
(2)

where $x_{C_2H_4,inlet}$ and $x_{C_2H_4,outlet}$ denote the volumetric concentration of ethylene at the reactor inlet and outlet, respectively. The selectivity of a reaction product *j*, *S*(*j*), was calculated according to eq 3

$$S(j) = \frac{x_j/n_j}{\sum x_j/n_j} \times 100\%$$
(3)

where x_j and n_j denote the volumetric concentrations of product *j* at the reactor outlet and the corresponding stoichiometric factor with respect to the number of carbon atoms, respectively (e.g., $C_2H_4 + 2O_2 \rightarrow 2CO + 2H_2O$, $n_{CO} = 2$).

The carbon mass balance error $\varepsilon_{\rm C}$ was determined using eq 4

$$\varepsilon_{\rm C} = \left| \frac{x_{\rm C_2H_{4},j,inlet} - \sum x_{\rm C_2H_{4},j,outlet} / n_{\rm C_2H_{4},j,outlet}}{x_{\rm C_2H_{4},j,inlet}} \right| \times 100\%$$
(4)

where $x_{C_2H_{4j}}$ and $n_{C_2H_{4j}}$ denote the concentration of ethylene or product *j* at the reactor inlet or outlet and the corresponding stoichiometric factor with respect to the number of carbon atoms, respectively. Each catalytic data point reported is an average of at least three measurements. The carbon mass balance in all catalytic tests closed at 96% or higher. After the tests, the catalyst bed was quenched to room temperature in He flow.

2.4. Temporal Analysis of Products. Overall reaction pathways of product formation in ethylene oxychlorination over

an equilibrated catalyst sample (CeO₂-873-E673) were studied by temporal analysis of products (TAP), a transient pulse technique with a time resolution of approximately 100 μ s.⁴⁶ The used TAP-2 system is equipped with an in-housedeveloped quartz-tube fixed-bed reactor ($d_{in} = 6 \text{ mm}, L = 40$ mm) in which the catalyst ($W_{cat} = 65$ mg, particle size $d_p = 0.3 -$ 0.5 mm) was packed between two layers of quartz of the same particle size within the isothermal zone of the reactor. Then, the reactor was evacuated stepwise to 10^{-5} Pa. The pulse experiments were carried out at 673, 723, and 773 K using $C_2H_4:Ne = 1:1, C_2H_4:O_2:Ne = 1:1:1, HCl:Ar = 1:1, Cl_2:Ar =$ 1:1, and $C_2H_4Cl_2$:Ar = 1:6 mixtures. An overall pulse size was around 10¹⁶ molecules. Ne (Linde Gas, 5.0), Ar (Linde Gas, 5.0), O₂ (Air Liquide, 4.8), C₂H₄ (Air Liquide, 3.5), EDC (Sigma-Aldrich, 99.8%), and HCl (Air Liquide, 4.5, anhydrous) were used for preparing reaction mixtures without additional purification. A quadrupole mass spectrometer (HAL RC 301 Hiden Analytical) was used for quantitative analysis of feed components and reaction products, where the following AMUs were assigned for mass spectrometric compound identification: 70 (Cl₂), 66 (EC), 64 (EC, EDC, VCM), 62 (EDC, VCM), 49 (EDC), 44 (CO₂), 36 (HCl), 32 (O₂), 29 (EC), 28 (EC, EDC, CO₂, CO, C₂H₄), 27 (EC, EDC, VCM, C₂H₄), 26 (EC, EDC, VCM, C₂H₄), 22 (Ne), 18 (H₂O), 2 (H₂O, H₂), 40 (Ar) and 20 (Ar, Ne). Pulses were repeated 10 times for each AMU and averaged to improve the signal to noise ratio.

2.5. Density Functional Theory. All calculations were performed with periodic boundary conditions at the density functional theory level, implemented in the Vienna ab initio simulation package (VASP, version 5.3.5),^{49–51} using the Perdew–Burke–Ernzerhof (PBE) functional.⁵² Projector-augmented wave (PAW) pseudopotentials were used to consider the inner electrons, whereas valence electronic states were expanded in plane waves with an energy cutoff of 500 eV. 53 In order to reduce the self-interaction error, an effective Hubbard potential (U_{eff}) of 4.5 eV was added to the Ce(4f) states.⁵⁴ Spin-polarized calculations were performed when required. van der Waals contributions were included by using the D3 dispersion correction method of Grimme et al.⁵⁵ The criteria for electronic and geometry optimization convergence were set to 10^{-6} eV and 0.015 eV Å⁻¹, respectively. The lattice parameter of CeO₂ was optimized with a dense $7 \times 7 \times 7 \Gamma$ centered k-point mesh and an energy cutoff of 700 eV, leading to the lattice parameter $a_{calc} = 5.492$ Å, which is in good agreement (1.5% deviation) with the experimental value of a_{exp} = 5.411 Å.⁵⁶ The investigated (111) surface was thereafter modeled as periodically repeated slabs using a $3 \times 3 \times 1$ Γ centered k-point mesh. The slabs were separated by 15 Å of vacuum space on top and consisting of 3×3 unit cells with three and six layers of Ce and O atoms, of which the upper two Ce and four O layers were allowed to relax. Chlorination of the surface was considered in the uppermost layer by replacement of O atoms with Cl atoms. The regular O-terminated $CeO_2(100)$ surface was modeled as a 2 \times 2 supercell as described in the literature with the same k-point sampling and vacuum space as for the (111) surface.⁵⁷ The climbing image nudged elastic band (CI-NEB) method and corresponding vibrational analysis were used to identify the transition states in the reaction network.^{58,59} The structures, labeled with the same names as described in this work, are freely accessible from the ioChem-BD database.^{60,61} The vibrational, rotational, and translational entropies of gas-phase molecules were calculated using Gaussian 03W (Version 6.1), 62 employing DFT with PBE



Figure 1. Ethylene conversion (*X*) and selectivity (*S*) versus temperature ramping up (arrow 1, open symbols) and down (arrow 2, solid symbols) over (a) CeCl₃-423, (b) CeOCl-1023, and (c) CeO₂-1023. Other conditions: C_2H_4 :HCl:O₂ = 3:4.8:3, W_{cat} = 0.5 g, F_{tot} = 100 cm³ STP min⁻¹, P = 1 bar. XRD patterns of fresh (bottom) (d) CeCl₃-423 (green), (e) CeOCl-1023 (blue), and (f) CeO₂-1023 (black) with corresponding reference patterns of CeCl₃ (ICDD PDF 77-0154 and 01-0149), CeOCl (ICDD PDF 73-5027), and CeO₂ (ICDD PDF 73-6318) and used catalysts (top, red) that all show only the CeO₂ phase corresponding again to ICDD PDF 73-6318. (g-i) HRTEM images (left) and elemental maps (right, where red depicts O and green Cl, respectively) of used catalysts corresponding to (a)–(c).

functionals, a cc-pVQZ basis set, the RMS force criterion set to 10^{-5} , and the temperature set to 673.15 K. The Gibbs free energy was calculated by taking the vibrational entropy into account, as implemented in Gaussian and described by Ochterski.⁶³

3. RESULTS AND DISCUSSION

3.1. Effect of Material Properties. In order to choose the right model catalyst for this study, the first step was to identify which type of material is present during the reaction by correlating steady-state activity with the bulk-phase composition. Figure 1a-c depicts the conversion of ethylene and selectivity to various products in ethylene oxychlorination on CeCl₃, CeOCl, and CeO₂. The temperature was cycled from 423 to 723 K and backward in order to achieve the strongest hysteresis behavior, as it can be expected that CeCl₃ transforms to the oxide under an oxygen-containing atmosphere at high temperatures. The material that behaves quite differently from the rest during up- and downcycling is CeCl₃, which shows first only formation of ethyl chloride before the conversion drops to almost zero until 723 K, where about 58% conversion is reached. At this temperature, the product distribution is similar to that of CeOCl and CeO₂, while the activity is about the same as that of CeOCl and a bit higher than that of CeO₂. However, most importantly, the cooling part of the cycle is qualitatively the same in all three materials, suggesting a transformation of the different starting materials to one and the same phase. As CeOCl and CeO₂ do not exhibit such a hysteresis behavior, it is likely that this common phase is an oxychloride, which either exists from the beginning in CeOCl or forms easily and quickly from CeO₂ through chlorination already at low temperatures. XRD evidences the prevalence of bulk CeO₂ in all samples after the test (Figure 1d-f), whereas elemental mapping (Figure 1g-i) shows the presence of oxygen and chlorine throughout all samples. Previous studies of HCl oxidation report that CeO₂ mainly chlorinates on the surface or only to some extent in the near-subsurface region at O_2 :HCl feed ratios greater than $0.75_{,3}^{,32} 1_{,3}^{,37}$ or $2_{,6}^{,64}$ constituting a rather large spread.

As the ethylene oxychlorination reaction conditions used are in general closer to those reported in the first two publications, ceria was previously proven to be stable in oxychlorination of ethylene,²⁷ and the XRD patterns of catalysts used in Figure 1d-f only show the presence of the oxide phase, we estimate that the bulk material keeps the oxide nature while the catalytically active surface consists of an oxychloride. In addition, key DFT calculations show that the energy required to displace one Cl atom from the surface to a subsurface position is 3 eV,³² indicating that this is an unlikely event. The CeOCl and CeO₂ samples used exhibit mostly octahedral morphologies, whereas the CeO₂ formed from CeCl₃ shows less developed crystals, likely due to insufficient oxygen availability during such a transformation. However, this insight into the composition of the surface does not yet allow conclusions about which facet of chlorinated ceria should be the model surface for further studies. Therefore, we investigated the performance of polycrystalline ceria and CeO₂ nanocubes (CeO₂-873-E673 and CeO₂-NC-E673), exposing predominantly the (111) and (100) surfaces, respectively. Figure S1 shows that there are no significant differences in selectivity between the nanocubic and polycrystalline samples when they are compared at equal conversion (Figure S2 depicts the relationship of conversion and product distribution of our standard sample). The only difference is the slightly decreased combustion in favor of higher selectivity to chlorinated hydrocarbons of CeO2-NC-E673, which can be explained by easier chlorination of the (100) surface in comparison to the (111) surface, evidenced by a much higher net (Table S1) and per surface area (Figure S1) chlorine uptake. The latter is likely also a reason for the reduced activity, together with the lower surface area of the nanocubes used (19 versus 39 m² g⁻¹).



Figure 2. (a) Conversion and selectivity of ethylene oxychlorination at 673 K on CeO₂-873 without pretreatment and with a prereduction in 5 vol % H_2 at 873 K for 2 h. The right axis indicates the chlorine content per surface area of the used catalysts (see also Table S1). Other conditions: C_2H_4 :HCl:O₂ = 3:4.8:3, W_{cat} = 0.5 g, F_{tot} = 100 cm³ STP min⁻¹, P = 1 bar, time on stream 2 h. The insets schematically depict the principle of chlorination, where the top part shows CeO₂ with a low or high amount of vacancies formed by prereduction, which leads to low or high chlorination (yellow Ce, red O, green Cl). (b, c) HRTEM images and (d, e) elemental mapping of CeO₂-873-E673 and CeO₂-873-P873-E673. The scale bars in the micrographs represent 100 nm.

Studies of HCl oxidation and trimethoxybenzene oxyhalogenation have previously shown similar results, where nanooctahedra exhibited a higher activity per surface area in comparison to nanocubes.^{64,65} However, the chlorine uptake was therein reported higher on the octahedra than on the cubes, in contrast with our findings, which is most likely linked to the different conditions and absence of ethylene.⁶⁴ Furthermore, while the stabilities of the two different CeO₂ morphologies under the reaction conditions are comparable, as evidenced by HRTEM analysis of fresh and used samples (Figure S1b–e), the (111) surface is generally more stable from a thermodynamic point of view.⁶⁶

However, as the effect of oxygen vacancies and their possible chlorination is yet unclear, we conducted experiments with in situ prereduced CeO2, in order to create vacancies before exposing the material to our reaction conditions. These vacancies can be filled by oxygen or chlorine during the reaction, as depicted in the schemes in Figure 2a (see Table S1 for surface areas and chlorine contents), while chlorination is preferred by 0.89 eV (vide infra). In turn, the higher degree of chlorination leads to less activity, less combustion, and improved EDC selectivity of CeO₂-873-p873-E673 with respect to the reference sample CeO_2 -873-E673 (Figure 2a). Even though the structure is preserved in both cases (HRTEM images of used catalysts show no significant differences and octahedra are still clearly visible), elemental mapping also evidences much more chlorine in CeO2-873-p873-E673 than in CeO₂-873-E673 (Figure 2b-e), confirming the XRF measurements. Therefore, vacancies are at least partially healed by incorporation of chlorine rather than oxygen under the reaction conditions, thus creating a surface oxychloride structure and constituting an important factor determining the selectivity. The number of vacancies that form under reaction conditions was determined by measurement of the oxygen storage capacity (OSC), a technique widely applied in the literature.

In general, an increase in the OSC of used materials in comparison to fresh CeO₂ (50 μ mol O₂ g⁻¹ for CeO₂-873-E673 versus 34 μ mol O₂ g⁻¹ for CeO₂-873) is observed. This increase in OSC would suggest that, during reaction, the surface

or bulk of CeO₂ is modified by the introduction of chlorine, which can then alter the way CeO_2 interacts with H_2/O_2 during OSC measurements. Detection of chlorine traces by XRF (0.7 atom %) in the sample even after four reduction/oxidation cycles indicates that chlorine modifies the material permanently. This is also evidenced by the OSC value, which stays constant at ca. 50 μ mol O₂ g⁻¹ after three cycles. The literature supports the presence of nonremovable chlorine in ceria, suggesting that CeOCl patches which form on the surface can grow into subsurface layers at temperatures at or above 673 K.^{67,68} Furthermore, Cl was found to remain in the lattice until 1173 K under reducing conditions.⁶⁹ Interestingly, prereduction of CeO_2 with 5 vol % H_2 in He at 873 K has the same effect on the OSC as the oxychlorination reaction carried out at 673 K (CeO₂-873-p873 and CeO₂-873-E673 both exhibit an OSC of exactly 50 μ mol O₂ g⁻¹). Furthermore, the prereduced sample after reaction CeO2-873-p873-E673 also exhibits an OSC of 53 μ mol O₂ g⁻¹. This corroborates the assumption that the incorporation of nonremovable chlorine in the bulk does facilitate vacancy formation in other areas of CeO2, as also observed in a study on chlorine poisoning of Ce/Zr mixed oxide catalysts.⁷⁰ However, further investigations of these aspects would go beyond the scope of this work. In conclusion, vacancies and chlorination are strongly linked and cannot be discussed separately. While the existence of vacancies seems important to allow a certain extent of surface chlorination which suppresses combustion and allows the reaction to take place, too many vacancies, leading to too high chlorination, are detrimental to the performance. Furthermore, even though it cannot be excluded that chlorine atoms from the surface diffuse into subsurface layers, substantial subsurface chlorine populations are unlikely, as they correspond to highly endothermic processes. Taking all of the above into account, a stoichiometric $CeO_2(111)$ surface as reference and the same surface with one defect, i.e., one vacancy that can be filled by one chlorine atom, became the surfaces of choice for the DFT investigations.

3.2. Reaction Mechanism. Initial calculations of the two model surfaces showed the existence of three distinct adsorption sites, of which the stoichiometric surface exhibits

two (lattice oxygen and lattice cerium atoms) and the defective surface exhibits an oxygen vacancy in addition. HCl adsorbs dissociatively on $CeO_2(111)$, where the hydrogen proton binds to a lattice oxygen and the chlorine anion adsorbs either on top of a Ce atom ($E_{ads} = -1.40 \text{ eV}$) or in an oxygen vacancy ($E_{ads} =$ -3.16 eV). As the difference in adsorption energy is relatively high, it is plausible that, once vacancies exist, chlorine will predominantly fill them, in accordance with high Cl activation barriers in HCl oxidation.³² In contrast to the (111) surface, HCl adsorption on the regular O-terminated (100) surface⁵⁷ is much stronger $(E_{ads}(HCl) = -3.64 \text{ eV} \text{ and } E_{ads}(2HCl) = -6.08$ eV) and Cl evolution is very energy intensive (2.64 eV) and thus unlikely. Therefore, once HCl adsorbs on $CeO_2(100)$, Cl is very likely to stay on that surface, thus poisoning it, which explains the relative inertness of this surface. Similar to HCl adsorption on $CeO_2(111)$, even though nondissociative, chlorinated hydrocarbons also occupy up to three adsorption sites simultaneously. While ethylene adsorbs on top of a lattice cerium, chlorinated hydrocarbons occupy one lattice oxygen and neighboring Ce atoms or vacancies (Figures S3 and S4). The same holds for chemisorbed intermediates, where lattice oxygen creates a bond to one C atom and the potential chlorine ends orient so that they occupy Ce atoms or vacancies (vide infra). A comparison of the adsorption energies of ethylene and chlorinated products on a stoichiometric, an oxygen vacant, and a chlorinated surface (Figure 3 and Table S2) shows that



Figure 3. Adsorption energies of ethylene and chlorinated products on a stoichiometric surface (stoich) and two defect surfaces with either one oxygen vacancy (1 vac) or one incorporated chlorine atom (1 Cl).

ethylene is generally weakly adsorbed and EDC is always the most strongly adsorbed compound, with the exception of the case with one oxygen vacancy, where EC adsorbs with the same energy. DCE exhibits a slightly weaker adsorption, similar to the case for EC, while VCM is always the least strongly bound product. Therefore, EDC, EC, and DCE are more likely to take part in further transformations in comparison to VCM if the barriers are reasonably low. This is very desirable, however, VCM is only on the stoichiometric surface less strongly adsorbed than ethylene and the adsorption energies of all products on the oxygen vacant surface are very close. The latter can be explained by the fact that the presence of a vacancy acts as an ideal trapping site for the chlorinated end of each molecule and therefore other contributions are less important (Figure S4). Nevertheless, the result of this comparison is not in line with the experimentally observed selectivity (Figures 1 and 2 and Figure S2) and therefore not sufficient to unravel the mechanism of ethylene oxychlorination on CeO2

Our previous work proposes a sequential mechanism of ethylene oxychlorination to EDC and its dehydrochlorination to VCM, as depicted in dashed black lines in Figure 4, which represents the starting point of a transition state investigation on a stoichiometric and defective surface. However, some elementary steps in this pathway are highly unlikely due to high barriers for the formation of EDC (stoichiometric 1.98 eV, defective 2.77 eV, step 3 in Table S2). In addition, step 14 rendered unfeasible, as the removal of one chlorine atom always also involves the stripping of the second chlorine atom, leading to a surface-bound C₂H₃. Therefore, this pathway needs to be discarded, but an alternative consecutive mechanism could be imagined by ceria enabling concerted steps,⁷¹ i.e., the combination of individual steps into one elementary step, as depicted by solid black arrows in Figure 4. Herein, path 1a combines the addition of one chlorine atom from a vacancy and another chlorine atom that is adsorbed on top of a cerium atom to ethylene. The following path 7a represents the simultaneous abstraction of H and Cl from EDC, directly leading to VCM. Figure 5 and Table 1 report the reaction profile along these paths.

In fact, step 1a was found to consist of two individual steps (reaction coordinates 2-6, steps 1a-1 and 1a-2) with barriers of 1.16 and 0.60 eV, as the chlorine addition is not fully symmetric and thus a non-surface-bound C2H4Cl intermediate with only real frequencies exists. In other words, after ethylene and HCl adsorption from the gas phase, ethylene attacks the chlorine on top of a cerium atom (reaction coordinates 2-4), while in the second part, this intermediate directly picks up the chlorine from a vacancy (left inset in Figure 5). Nevertheless, this path is still greatly favored over the two individual steps with a surfacebound C2H4Cl intermediate or the situation with two chlorinated vacancies ($E_a > 3$ eV). Therefore, it cannot be considered a single elementary step, most likely because it encompasses the rotation that creates the reacting intermediate. On the other hand, the third transition state at reaction coordinate 7 (right inset in Figure 5) involves a truly simultaneous stripping of one chlorine by a vacancy and one hydrogen by a lattice oxygen, resulting in a barrier of only 0.48 eV. In contrast to the previous steps, this H-Cl extrusion does not involve a rotation, allowing the creation of a largely stabilized six-membered ring, formed by the surface and the transition state structure. Plots of the charge density (insets in Figure 5) evidence this hypothesis. However, EDC is the dominating product in comparison to VCM as experimentally observed, which can be explained by the lower ΔG value for EDC desorption in comparison to the barrier for its transformation to VCM.

In mechanistic investigations through density functional theory, selectivity is retrieved by the comparison of the desired path against potential side routes leading to the same or secondary products. Such an alternative route to form VCM could be offered by dehydrogenation of C_2H_5Cl (EC) or its corresponding intermediate C_2H_4Cl . However, while the latter is in principle possible with a barrier of 1.68 eV (path 4 in Figures 4 and 6 and Table 2), EC formation itself is highly unlikely. While the stoichiometric surface prohibits EC formation completely, the defect surface allows at least a very easy transformation of a surface alcohol (C_2H_4ClOH) to EC ($E_a = 0.04 \text{ eV}$). However, such a surface alcohol formation is strongly endothermic ($E_r = 1.5 \text{ eV}$) and thus the formation of EC can be excluded (path 2, 2a, 5, 6, 8 in Figure 4 and Figure S13 and Tables S3 and S4).



Figure 4. Schematic reaction network showing the main pathway (solid black) leading to EDC and VCM and side pathways leading either to VCM (light blue) or chlorinated side products (orange, magenta, purple, blue, gray). Solid (dashed) boxes indicate desired (undesired) products. For the sake of clarity, all truly reversible reactions are displayed in a single direction. The arrow labels indicate the transferred atom and the reaction number corresponding to Table S2 and Figures S5–S12. The main path leading to the desired product is highlighted by the black thick arrows. Dashed arrows represent pathways that were found to be highly unlikely. Surface-bound intermediates are depicted with a surface excerpt of two Ce and one O atom. The barrier of surface Cl diffusion (step 5) was 0.40 eV.



Figure 5. Reaction profile and corresponding optimized structures for ethylene oxychlorination and EDC dehydrochlorination on a defective $CeO_2(111)$ surface (solid black pathway, i.e. steps 1a and 7a in Figure 4 and Table S2) including the Gibbs free energy difference for desorption. The reaction coordinates are described in Table 1. The blue glow in the structures highlights a vacancy. The insets depict one individual (left) and a concerted (right) transition state. The yellow overlay represents the charge density (isosurface level 0.2309 $|e^{-|}|^{A^{-3}}$). Color code: oxygen, red; cerium, yellow; carbon, black; chlorine, green; hydrogen, white.

Formation of the undesired byproducts *cis*- and *trans*-DCE is possible through steps 11 and 13 from the surface-bound intermediate $C_2H_3Cl_2$ (Figure S14 and Table S5), favoring the cis isomer, which reflects the experimental observation. However, this mechanism is rather unlikely, as it only works on a stoichiometric surface or patches where no vacancy is near. Otherwise, the concerted step 7a would directly lead to VCM and the necessary surface intermediate would not exist. Furthermore, even on a stoichiometric surface, step 7a exhibits only a barrier of 0.61 eV, which is 0.56 eV lower than the formation of the necessary intermediate (step 7), making this path even more unlikely. Both alternative pathways to yield DCE (blue and gray in Figure 4, steps 9, 10, 12, 15) with VCM or EDC as a starting point exhibit relatively high barriers.

Table 1. Intermediates, State Descriptions, Energies with Respect to Gas-Phase Reactants (ΔE), Reaction Energies with Respect to the Previous Intermediate (E_r), Activation Energies (E_a), and Imaginary Frequencies of Transition States (ν_i), Corresponding to Figure 5^{*a*}

intermediate	state description	ΔE (eV)	$E_{\rm r}~({\rm eV})$	$E_{\rm a}~({\rm eV})$	$\nu_{\rm i}~({\rm cm}^{-1})$
1	$C_2H_4(g) + 2 \text{ HCl}(g) + \Box + 2^* + 2$	0			
2	$C_2H_4^* + Cl + Cl^* + 2 H$	-4.90	-4.90		
3	$C_2H_4^*$ - $-Cl = + Cl^* + 2 H$	-3.74		1.16	254
4	$C_2H_4Cl^{*}$ + Cl^{*} + 2 H	-3.99	0.91		
5	$C_2H_4Cl^{Cl^{+}+2}H_{-}$	-3.39		0.60	239
6	$C_2H_4Cl_2*\Box* + 2 H$	-3.70	0.29		
7	$C_2H_3Cl^{**}$ Cl + 2 H	-3.22		0.48	612
8	$C_{2}H_{3}Cl^{**} + Cl + 3 H$	-5.72	-1.94		

^{*a*} The symbol \blacksquare denotes a lattice oxygen, \square an oxygen vacancy, and * a lattice cerium, respectively. Multiple symbols indicate occupation of multiple sites by the adsorbate. In transition states, the added or stripped atom is indicated with a double dash (--).



Figure 6. Reaction profile and corresponding optimized structures for direct VCM formation from ethylene on a defective $CeO_2(111)$ surface (light blue pathway, i.e. steps 1 and 4 in Figure 4 and Table S2) including the Gibbs free energy difference for desorption. The reaction coordinates are described in Table 2. The blue glow in the structures highlights a vacancy. The color code is the same as in Figure 5.

Table 2. Intermediates, State Descriptions, Energies with Respect to Gas Phase Reactants (ΔE), Reaction Energies with Respect to the Previous Intermediate (E_r), Activation Energies (E_a), and Imaginary Frequencies of Transition States (ν_i), corresponding to Figure 6^{*a*}

intermediate	state description	ΔE (eV)	$E_{\rm r}~({\rm eV})$	$E_{\rm a}~({\rm eV})$	$\nu_{\rm i}~({\rm cm}^{-1})$
1	$C_2H_4(g) + HCl(g) + \Box + * + 2$	0			
2	$C_2H_4^* + Cl + H + H$	-3.79	-3.79		
3	$C_2H_4^*-Cl + H$	-2.61		1.18	278
4	C_2H_4Cl* + H + H	-3.38	-0.40		
5	$C_2H_3Cl^{-}-H$ + H	-1.71		1.67	450
6	$C_2H_3Cl^{*}$ + 2 H	-2.99	-0.39		

^aThe symbol denotes a lattice oxygen, and an oxygen vacancy, and a lattice cerium. Multiple symbols indicate occupation of multiple sites by the adsorbate. In transition states, the added or stripped atom is indicated with a double dash, - -.

However, due to strong VCM and even stronger EDC adsorption on a vacancy, the blue and gray paths, both favoring the cis isomer, seem to represent the more likely mechanism of DCE formation (Figure 7 and Tables 3 and 4). Counterbalancing this process is only the fact that, even though VCM or EDC is strongly adsorbed on a vacancy, it can easily be displaced by HCl or O_2 adsorption.

Oxidation processes were studied by investigating the energy barriers of chemisorption of ethylene and VCM on a molecular O_2 in a vacancy, which were both very low (0.88 and 1.01 eV). However, the probability of such a setting existing is extremely low, as O_2 would easily split up when another vacancy is present (barrier of 0.80 eV), refilling of two vacancies (surface and subsurface) is possible,³² and chemisorption of a

(chlorinated) gas-phase hydrocarbon is not possible on a lattice oxygen on the $CeO_2(111)$ surface. Furthermore, the adsorption energy of HCl is 0.89 eV higher than that of O_2 , resulting in the preferential adsorption of HCl. As O_2 activation leaving active O atoms on the surface is unlikely, the lateral oxidation processes have not been investigated further.

3.3. Direct Chlorination and Gas-Phase Contributions. From previous studies, we know that CeO_2 exhibits considerable HCl oxidation activity at conditions close to our reaction conditions,^{28,32} prompting an investigation of gas-phase and direct chlorination contributions. As depicted in Figure 8a,b, direct chlorination, i.e., addition of Cl₂ to ethylene, or formation of VCM through replacement of H by Cl reaches about 50% conversion over quartz particles and about 60%



Figure 7. Reaction profile and corresponding optimized structures for DCE formation from VCM (end of step 4, Figure 6) on a defective $CeO_2(111)$ surface through steps 9, 10, and 12 in Figure 4 and Table S2 (left), with the reaction coordinates described in Table 3. Reaction profile and corresponding optimized structures for DCE formation from EDC (end of step 1a-2, Figure 5) on a defective $CeO_2(111)$ surface through step 15 (right), with the reaction coordinates described in Table 4. The color code is the same as in Figure 5.

Table 3. Intermediates, State Descriptions, Energies with Respect to Gas-Phase Reactants (ΔE), Reaction Energies with Respect to the Previous Intermediate (E_r), Activation Energies (E_a), and Imaginary Frequencies of Transition States (ν_i), Corresponding to Figure 7^{*a*}

intermediate	state description	ΔE (eV)	$E_{\rm r}~({\rm eV})$	$E_{\rm a}~({\rm eV})$	$\nu_{\rm i}~({\rm cm}^{-1})$
1	$C_2H_3Cl^{*}$ + 2 H + +	-2.99			
2	$C_2H_2Cl^{-}-H$ + 2 H	-1.51		1.48	1499
3	$C_2H_2Cl^* + 3 H + * + HCl(g)$	-4.40	-1.41		
4	$C_2H_2Cl^* + 4 H + Cl^*$	-5.57/-5.94	-1.17/-1.54		
5	c/t-C ₂ H ₂ Cl*□Cl* + 4 H	-3.84/-4.04		1.73/1.90	376/365
6	$c/t-C_2H_2Cl_2*\square* + 4$ H	-4.65/-4.59	0.92/1.35		

^aThe symbol denotes a lattice oxygen, and a oxygen vacancy, and a lattice cerium. Multiple symbols indicate occupation of multiple sites by the adsorbate. In transition states, the added or stripped atom is indicated with a double dash, - -.

Table 4. Intermediates, State Descriptions, Energies with Respect to Gas-Phase Reactants (ΔE), Reaction Energies with Respect to the Previous Intermediate (E_r), Activation Energies (E_a), and Imaginary Frequencies of Transition States (ν_i), Corresponding to Figure 7^{*a*}

intermediate	state description	ΔE (eV)	$E_{\rm r}~({\rm eV})$	$E_{\rm a}$ (eV)	$ u_{\rm i}~({\rm cm}^{-1}) $
1	$C_2H_4Cl_2*\square*+2$ H + 2	-3.75			
2	$C_2H_2Cl_2*\Box*H\BoxH\Box+2$ H	-2.12		1.63	601
3	$c-C_2H_2Cl_2*\Box* + 4 H$	-4.65	-0.90		

^a The symbol \blacksquare denotes a lattice oxygen, \square an oxygen vacancy, and * a lattice cerium. Multiple symbols indicate occupation of multiple sites by the adsorbate. In transition states, the added or stripped atom is indicated with a double dash, - -.

conversion over CeO₂-873 at 673 K. In both cases, VCM is the dominant product. In order to ensure that quartz particles were inert and did not catalyze the reaction, a pure gas-phase test was conducted in an empty reactor, yielding the exact same performance (Figure S15a). Considering that, under equivalent conditions, the degree of HCl conversion into Cl₂ reaches 10 or 5% over CeO₂-873 or CeO₂-NC (Figure 8c and Figure S15b)—and comparing the oxychlorination activity (Figure 8d) it can be expected that at 673 K about 6-8% in total might stem from gas-phase direct chlorination. Figure 8e depicts the gas-phase activation energies of EDC and VCM formation from ethylene in which direct addition of Cl₂ to ethylene to form EDC yields an energy barrier of 1.41 eV while being exothermic by -2.01 eV. In comparison to this direct addition, the literature also reports the possibility of radical-assisted mechanisms for direct halogenation, e.g., hydroxyl-assisted direct iodination of aromatics, highlighting the rich chemistry offered by halogenation reactions.⁷² The former barrier is only

beaten by its lower counterpart (1.32 eV) of direct VCM formation through a one-step dehydrogenation-Cl addition, where one hydrogen is stripped from ethylene by one Cl while the other Cl transfers to the C2H3 radical. The exothermicity of this reaction (-1.31 eV) is however lower than for EDC formation, implying that EDC dehydrochlorination is endothermic by 0.70 eV. In addition, the latter presents a very high energy barrier of 2.47 eV, excluding the dehydrogenation pathway in the gas phase. Even EDC-, HCl-, or O2-assisted dehydrochlorination, i.e., the presence of one of the above molecules in the close surroundings of EDC, did not significantly change the barrier. Prompted by this result, we conducted gas-phase dehydrochlorination of EDC with and without cofed HCl or O2, supporting the calculations, as no conversion could be observed until 723 K (6% only for cofed HCl; no conversion otherwise, Figure S15c). Thus, reactions in the gas phase predominantly yield VCM, as direct VCM



Figure 8. Conversion (X) and selectivity (S) versus temperature in steady-state catalytic tests of (a) direct chlorination with C_2H_4 : $Cl_2 = 3:2.4$ on quartz and (b) CeO₂-873, (c) HCl oxidation with HCl:O₂ = 4.8:3 on CeO₂-873, and (d) oxychlorination on CeO₂-873 with C_2H_4 :HCl:O₂ = 3:4.8:3. Other conditions: $W_{cat} = 0.5$ g, $F_{tot} = 100$ cm³ STP min⁻¹, P = 1 bar. (e) Reaction profile for gas-phase ethylene chlorination and subsequent EDC dehydrochlorination (black) and gas-phase direct VCM formation from ethylene (light blue).



Figure 9. Normalized transient responses of (a) Cl_2 , VCM, EDC, and CO_2 upon simultaneous pulsing of HCl:Ar = 1:1 and C_2H_4 : O_2 :Ne = 1:1:1 at 773 K and (b) VCM, EDC, and CO_2 upon simultaneous pulsing of Cl_2 :Ar = 1:1 and C_2H_4 : O_2 :Ne = 1:1:1 at 773 K.

formation is favored over EDC formation, while EDC dehydrochlorination is nonexistent.

3.4. Temporal Analysis of Products. In an attempt to corroborate the theoretical reaction scheme described above, we conducted transient experiments with submillisecond time resolution on pre-equilibrated CeO2-873-E673. Figure 9a depicts the height-normalized transient responses of Cl₂, EDC, VCM, and CO₂, recorded after simultaneous pulsing of HCl, C₂H₄, and O₂. Herein, Cl₂ was the first product detected at the reactor outlet followed by EDC, VCM, and finally CO₂. The same product formation sequence was observed in the absence of gas-phase O2 (i.e., when only HCl and C2H4 were simultaneously pulsed) (Figure S16). Notably, neither radicals nor EC was observed in these experiments, in agreement with the results of steady-state experiments and DFT. Therefore, the pink (8) and orange pathways (2 and 5, 6) of EC formation and its dehydrogenation to VCM in Figure 4 do not contribute to the overall reactivity. However, this does not necessarily exclude the second step of dehydrogenation (path 4 in Figure 4), which could still be part of the direct VCM formation from ethylene, even though it is not favored. Insight into this circumstance was indirectly derived from analyzing the order of appearance of EDC and VCM (Figure 9a), which suggests that C₂H₄ is initially converted into EDC followed by dehydrochlorination of the latter to VCM. This experimental finding supports the pathways predicted by DFT (i.e. $C_2H_4 \rightarrow EDC \rightarrow$

VCM, black arrows in Figure 4). As the same sequence of product formation was also observed in the absence of gasphase O_2 (Figure S16), the above statement should be valid for a broad range of coverage by oxygen and chlorine species, thus supporting the validity of our chosen defect model surface. In addition, this experiment also revealed a correlation between the amount of formed chlorine-containing products (EDC and VCM) and the amount of detected Cl_2 (Figure S17), suggesting that high chlorine coverage favors both the formation of EDC/VCM and desorption of Cl_2 . This statement is in line with the hypothesis that both processes take place in parallel and increased temperature, and thus less poisoning through faster Cl_2 evolution, leads to an increased yield of EDC and VCM.

In order to check if the source of chlorine, i.e. HCl or Cl_2 , influences the pathways of EDC and VCM formation, we performed experiments with simultaneous pulsing of Cl_2 , C_2H_4 , and O_2 . Figure 9b depicts the obtained height-normalized transient responses of EDC, VCM, and CO₂. The order of appearance of these products indicates that EDC is the first chlorinated hydrocarbon formed from ethylene, which is in agreement with tests using HCl as chlorine source. Therefore, the order of the reaction steps including chlorination of C_2H_4 to EDC and subsequent dehydrochlorination of this product to VCM does not depend on the source of chlorine. This statement is in line with the observation in our calculations that both HCl and Cl₂ immediately dissociate upon adsorption, regardless of vacancies being present or not.

In addition, the catalytic ability to dehydrochlorinate EDC was tested in separate experiments, resulting in the transient responses of EDC, VCM, CO, and CO_2 as shown in Figure 10. The first observed product was VCM, further supporting the conclusion about an intermediate role of EDC upon conversion of HCl and C_2H_4 to VCM.



Figure 10. Normalized transient responses of VCM, EDC, CO, and CO_2 upon pulsing of EDC:Ar = 1:6 at 773 K.

Even though combustion products (CO and CO₂) account for the smallest fraction of products, they are yet substantial and an understanding of their formation is important for improving the catalyst performance. CO was not detected when C₂H₄ and O₂ were simultaneously pulsed with HCl or Cl₂ (Figure 9). This is also valid for the ethylene oxidation reaction in the absence of Cl-contacting reactants (Figure S18). Although it cannot be completely excluded that CO was formed in tiny amounts, which are below the detection limit, the main unselective pathway of C2H4 conversion is its oxidation to CO₂. CO and CO₂ were observed when EDC reacted with the catalyst in the absence of gas-phase O2. It is also possible that these carbon oxides originated from VCM. Thus, both ethylene and its chlorinated products are responsible for the formation of CO_r in the course of ethylene oxychlorination. In addition, lattice oxygen species appear to actively participate in these undesired processes.

4. CONCLUSIONS

The combination of computational analysis by the application of density functional theory with steady-state experiments and investigation of transient kinetics by temporal analysis of products revealed the mechanism of ethylene oxychlorination on CeO2. Experimental results suggest that the catalytic material consists of an oxide, supporting a surface oxychloride during reaction conditions. In addition, surface alterations by formation and chlorination of vacancies are an important factor determining the selectivity. While empty vacancies decrease the selectivity to EDC or VCM, facilitating their further transformation to DCE, chlorinated vacancies enable the formation of EDC in the first place, as evidenced by an increase of selectivity to desired products with higher surface chlorination. Different facets of ceria ((111) and (100)) did not show significant performance differences except for lower activity of the polar (100) surface, which was related to lower overall surface area and higher chlorination (poisoning) of the sample. Thus, the most stable (111) surface of CeO₂ with one vacancy

was chosen as a model catalyst. We revealed that the formation of VCM most likely proceeds through dehydrochlorination of EDC which is greatly facilitated on the defect surface, while pure dehydrogenation pathways that require C2H5Cl as an intermediate could be excluded. The major finding, enabling easy EDC to VCM transformation and thus making the proposed pathway feasible, is the ability of ceria to perform concerted elementary steps. Most importantly, of the three types of theoretical concerted steps, HCl, H₂, or Cl₂ addition or abstraction, only HCl abstraction was found dominating and responsible for the excellent dehydrochlorination behavior of ceria, while H₂ abstraction is feasible. The cause for this easy concerted HCl abstraction can be found in the formation of a hexagonal structure that is formed by the electron densities of the involved C, Cl, H, O, and Ce atoms. Furthermore, formation of other polychlorinated byproducts such as DCE is possible from either EDC or VCM, with concerted H abstraction, or through individual steps from VCM, given that EDC or VCM is adsorbed on a vacancy. In other words, chlorinated vacancies facilitate the formation of EDC and its dehydrochlorination to VCM, staying chlorinated at the end of the process. However, VCM that is formed through an alternative, yet less important, direct path without EDC as intermediate leads to a non-chlorine-filled vacancy, acting as an anchoring site and increasing its adsorption, which then enables DCE formation. Given that the cis isomer is the only experimentally observed product, and EDC also occupies a vacancy after its formation, EDC appears to be more likely to transform to DCE in comparison to VCM. These observations are supported by transient kinetic studies that evidenced the oxychlorination-dehydrochlorination pathway by revealing that EDC is always formed as the first product, regardless of the chlorine source, followed by VCM. In addition, separate EDC dehydrogenation experiments substantiated this path, while the absence of ethyl chloride intermediates excluded pure dehydrogenation processes for VCM formation. Furthermore, we revealed that CO mostly stems from the combustion of chlorinated hydrocarbons, whereas ethylene yields only CO₂. Gas-phase chlorination, mostly yielding VCM, was found to be non-negligible, yet not governing, while EDC dehydrogenation is impossible in the gas phase.

The synergies obtained by the extensive combination of computational, steady state, and transient kinetic analysis in this study allow us to shed light on a complex reaction network of an industrially highly relevant reaction on CeO₂, providing a basis for further development and simulation of oxide- or oxychloride-based catalysts for oxychlorination reactions.

ASSOCIATED CONTENT

Supporting Information

Scheme of oxychlorination setup, additional characterization and catalytic data, optimized geometries of adsorbed species, and initial, transition state, and final geometries of elemental steps, additional reaction profiles, and additional TAP data (PDF)

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Notes

The authors declare no competing financial interest.

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